



Sheet 1 of 2

Form PTO-1449 Modified List of Patents and Publications Cited by Applicant (Use several sheets if necessary) U.S. Department of Commerce Patent and Trademark Office	Atty Docket No.: 16291-405	Serial No.: 10/658,950
	Applicant: Roman Skuratowicz	
	Filing Date: September 23, 2003	Group Art Unit: 1755

U.S. PATENT DOCUMENTS

*Examiner Initial		Doc. No.	Date	Name	Class	Sub- Class
DB	AA	2,749,336	06/05/56	Boddicker, et al.	260	231
	AB	3,015,572	01/02/62	Casey, et al.	106	197
	AC	3,723,413	03/27/73	Chatterjee, et al.	260	232
	AD	4,015,067	03/29/77	Lui, et al.	536	96
	AE	4,175,996	11/27/79	Battard, et al.	156	336
	AF	4,221,823	09/09/80	Pearson, et al.	427	4
	AG	4,272,295	06/09/81	Linke	106	157
	AH	4,297,144	10/27/81	Klein, et al.	106	197
	AI	4,492,729	01/08/85	Bannerman, et al.	428	283
	AJ	4,526,961	07/02/85	Perplies, et al.	536	98
	AK	4,568,714	02/04/86	Overholt	524	25
	AL	4,853,437	08/01/89	Lukach, et al	525	54.21
	AM	4,890,444	01/02/90	Vander Giessen, et al.	55	498
	AN	5,358,559	10/25/94	Fitt, et al.	106	213
	AO	5,369,155	11/29/94	Asmus	524	55
DB	AP	5,503,668	04/02/96	Giesfeldt, et al.	106	162



DB	AR	5,895,557	09/01/98	Saikia, et al.	536	124
	AS	5,932,639	04/20/99	Kronzer	162	168.1
	AT	5,939,544	08/03/99	Eden, et al.	524	48
	AU	6,352,845 B1	08/17/99	Karstens, et al.	536	124
	AV	6,368,443	03/05/02	Buchanan, et al.	435	105
	AW	6,388,069 B1	04/09/02	Fitt, et al.	156	205
	AX	2001/0020091 A1	05/14/02	Buchanan, et al.	536	72
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			09/13/01	Krammer, et al.	424	401

FOREIGN PATENT DOCUMENTS

*Examiner Initial	Doc. No.	Date	Country	Translation Yes No

OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

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Examiner <i>DM Brusman</i>	Date Considered <i>12/4/04</i>
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*Examiner: Initial if reference considered, whether or not citation is in conformation with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.